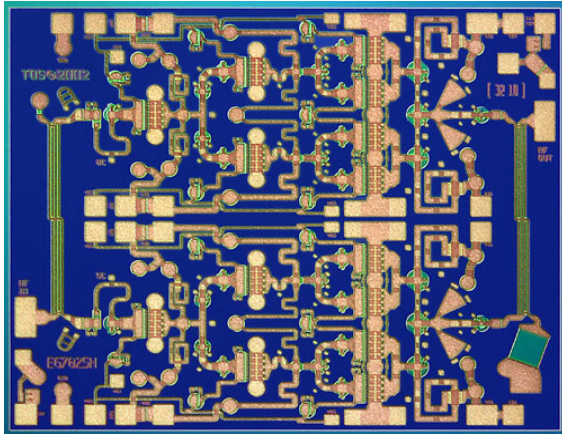


**27 - 31 GHz 2W Balanced Power Amplifier**

**TGA4513**

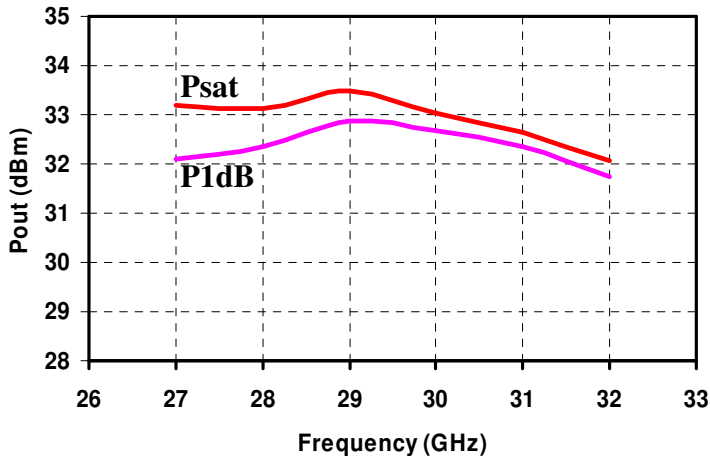
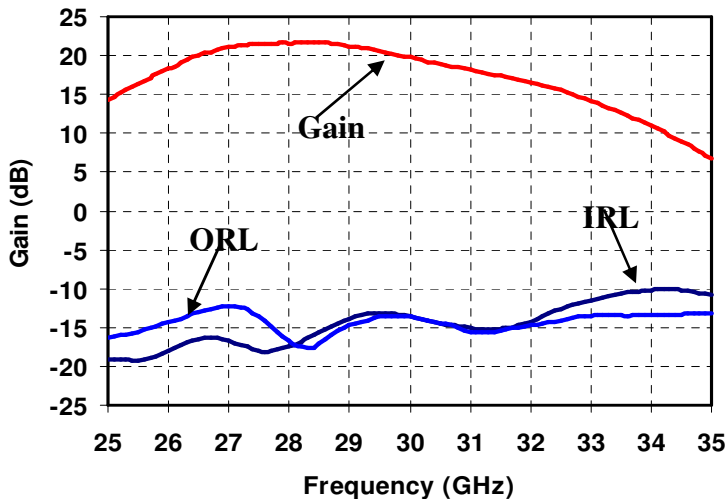


**Key Features**

- 27 - 31 GHz Bandwidth
- > 32 dBm P1dB
- 33 dBm Psat
- 20 dB Nominal Gain
- IMR3 is 37 dBc @ 18 dBm SCL
- 14 dB Nominal Return Loss
- Bias: 6 V, 840 mA
- 0.25 um 3MI MMW pHEMT Technology
- Chip Dimensions: 2.8 x 2.2 x 0.1 mm  
(0.110 x 0.087 x 0.004) in

**Measured Data**

Bias Conditions: Vd = 6 V, Id = 840 mA



**Primary Applications**

- Satellite Ground Terminal
- Point to Point Radio
- Point to Multi Point Radio
- LMDS

*Note: This device is early in the characterization process prior to finalizing all electrical specifications. Specifications are subject to change without notice.*

**TABLE I**  
**MAXIMUM RATINGS 1/**

<b>SYMBOL</b>	<b>PARAMETER</b>	<b>VALUE</b>	<b>NOTES</b>
V <sup>+</sup>	Positive Supply Voltage	7 V	2/
V <sup>-</sup>	Negative Supply Voltage Range	-3 TO 0 V	
I <sup>+</sup>	Positive Supply Current	1.86 A	2/
I <sub>G</sub>	Gate Supply Current	18 mA	3/
P <sub>IN</sub>	Input Continuous Wave Power	22 dBm	
P <sub>D</sub>	Power Dissipation	7.18 W	2/ 4/
T <sub>CH</sub>	Operating Channel Temperature	150 °C	5/ 6/
T <sub>M</sub>	Mounting Temperature (30 Seconds)	320 °C	
T <sub>STG</sub>	Storage Temperature	-65 to 150 °C	

- 1/ These ratings represent the maximum operable values for this device.
- 2/ Combinations of supply voltage, supply current, input power, and output power shall not exceed P<sub>D</sub>.
- 3/ Total current for the entire MMIC.
- 4/ When operated at this bias condition with a base plate temperature of 70 °C, the median life is 1.0E+6 hrs.
- 5/ Junction operating temperature will directly affect the device median time to failure (MTTF). For maximum life, it is recommended that junction temperatures be maintained at the lowest possible levels.
- 6/ These ratings apply to each individual FET.

**TABLE II**  
**DC PROBE TESTS**  
(T<sub>A</sub> = 25 °C Nominal)

SYMBOL	PARAMETER	MINIMUM	MAXIMUM	VALUE
I <sub>DSS1</sub>	Saturated Drain Current	60	282	V
G <sub>M1</sub>	Transconductance	132	318	mS
V <sub>BVGS1</sub>	Breakdown Voltage gate-source	-30	-8	V
V <sub>BVGD1</sub>	Breakdown Voltage gate-drain	-30	-11	V
V <sub>P1,8</sub>	Pinch-off Voltage	-1.5	-0.5	V

**TABLE III**  
**ELECTRICAL CHARACTERISTICS**  
(T<sub>a</sub> = 25 °C, Nominal)

PARAMETER	TYPICAL	UNITS
Drain Operating	6	V
Quiescent Current	840	mA
Small Signal Gain, S21	20	dB
Input Return Loss, S11	14	dB
Output Return Loss, S22	14	dB
Reverse Isolation, S12	-40	dB
Output Power @ 1 dB Compression Gain, P1dB	> 32	dBm
Power @ saturated, Psat	33	dBm
IMR3 @ 18 dBm SCL	37	dBc

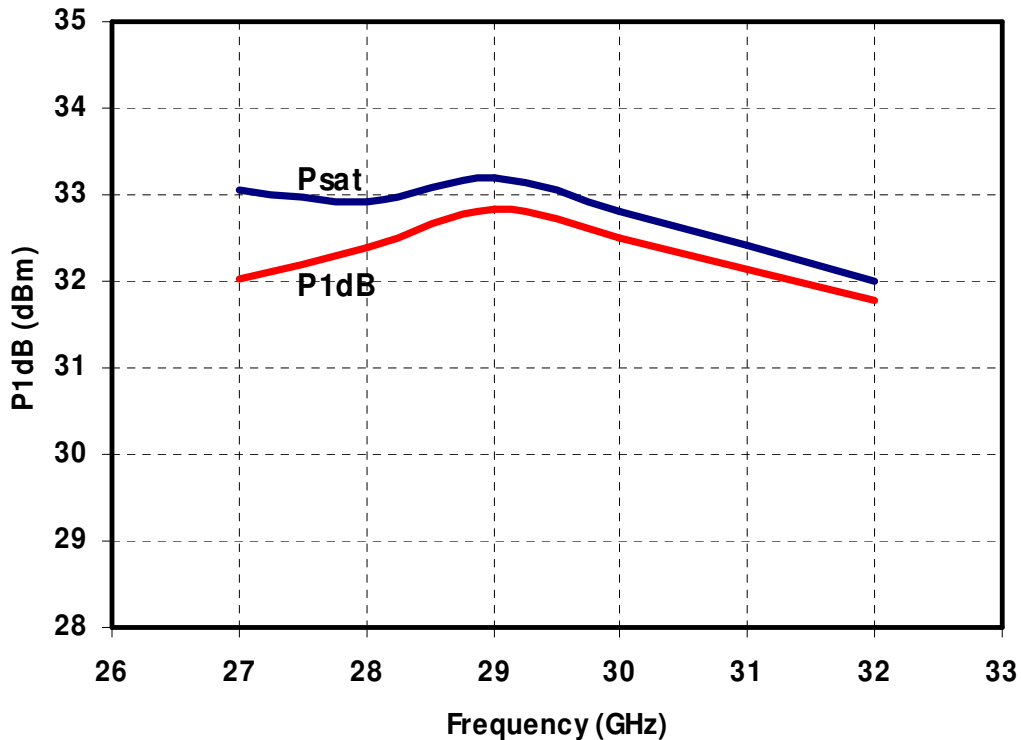
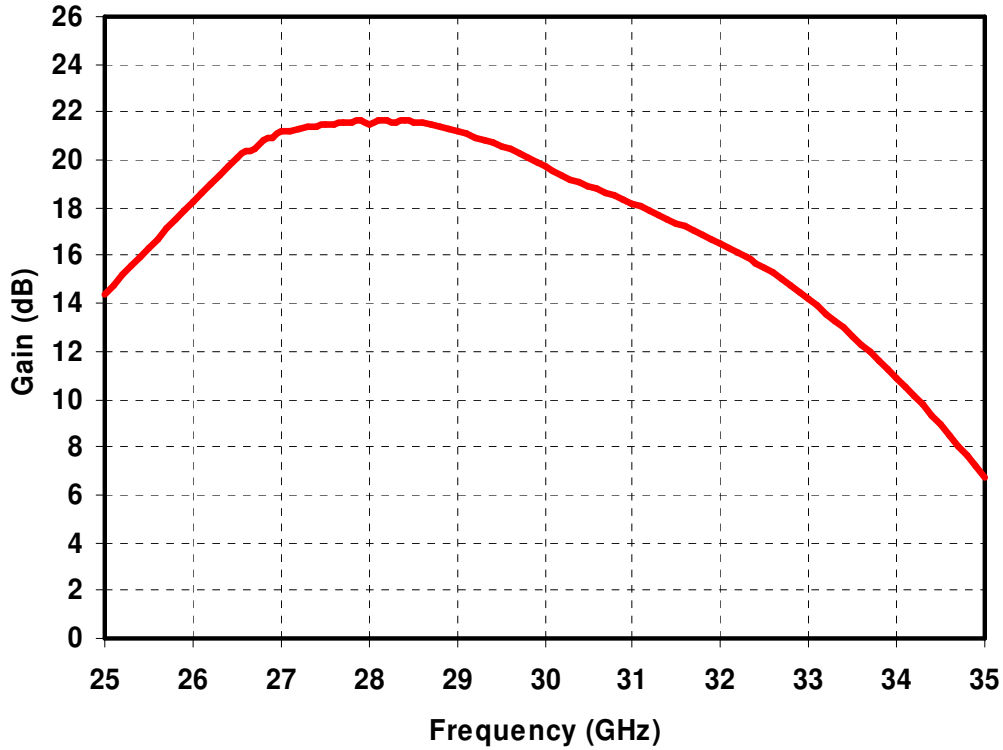
**TABLE IV**  
**THERMAL INFORMATION**

Parameter	Test Conditions	T <sub>CH</sub> (°C)	θ <sub>JC</sub> (°C/W)	T <sub>M</sub> (hrs)
θ <sub>JC</sub> Thermal Resistance (Channel Case)	V <sub>D</sub> = 6 V I <sub>D</sub> = 0.84 A (Quiescent) P <sub>DISS</sub> = 5.04 W T <sub>base</sub> = 70 °C	130.1	11.92	5.9 E+6

Note: Assumes eutectic attach using 1.5 mil 80/20 AuSn mounted to a 20 mil CuMo Carrier at 70°C baseplate temperature. Worst case condition with no RF applied, 100% of DC power is dissipated.

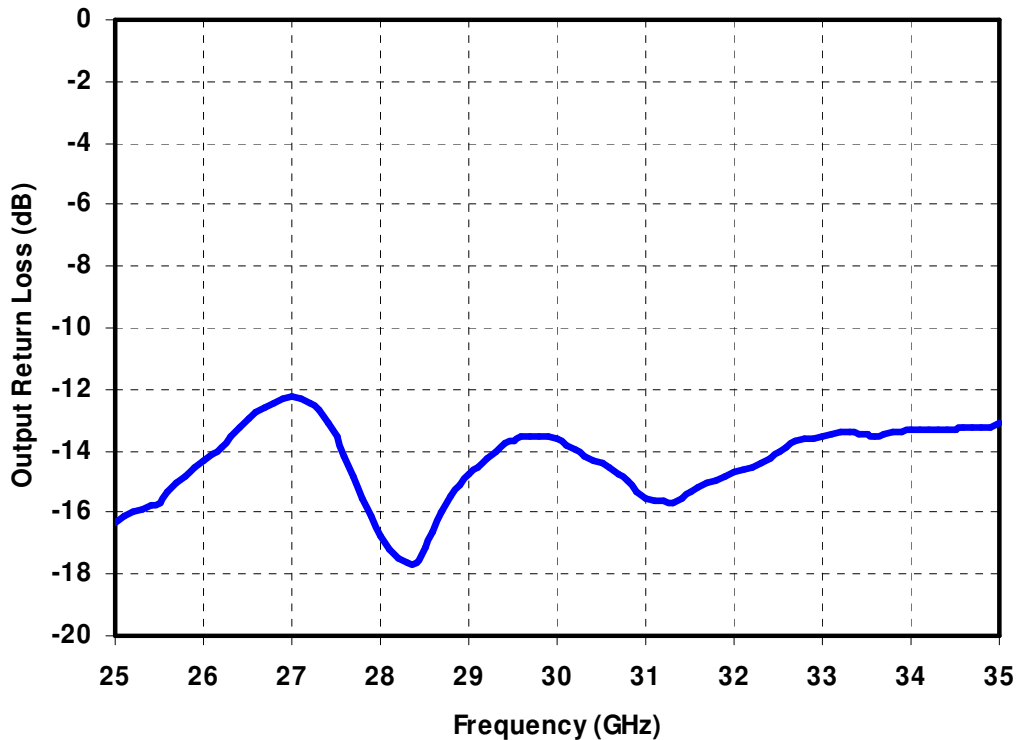
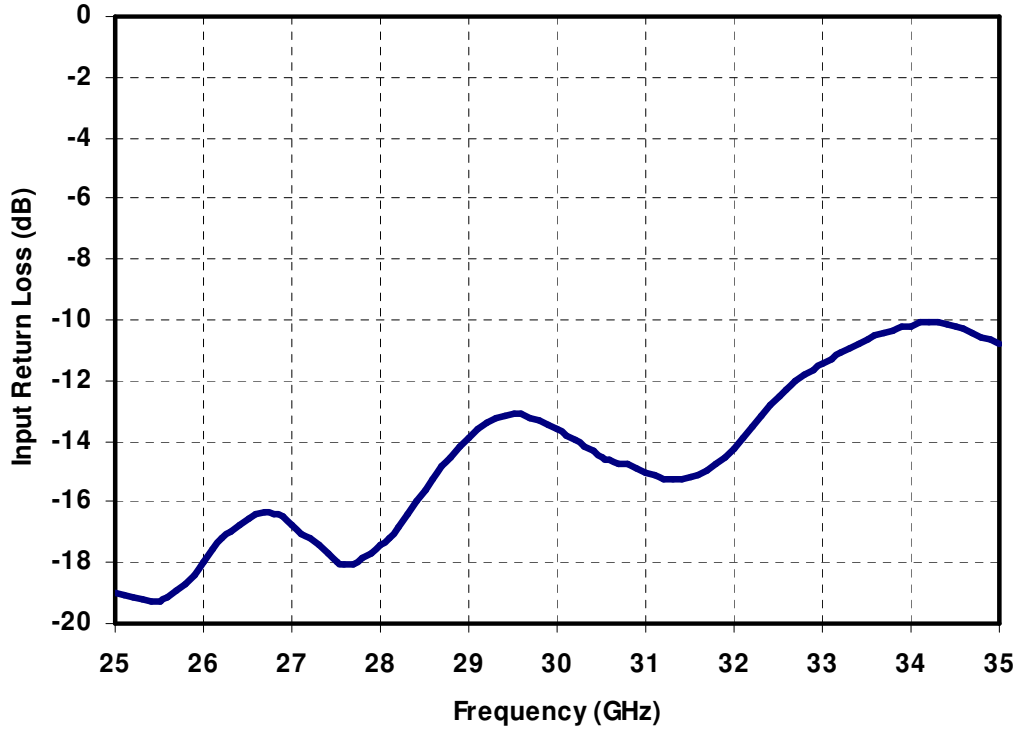
### Measured Data

Bias Conditions:  $V_d = 6\text{ V}$ ,  $I_d = 840\text{ mA}$



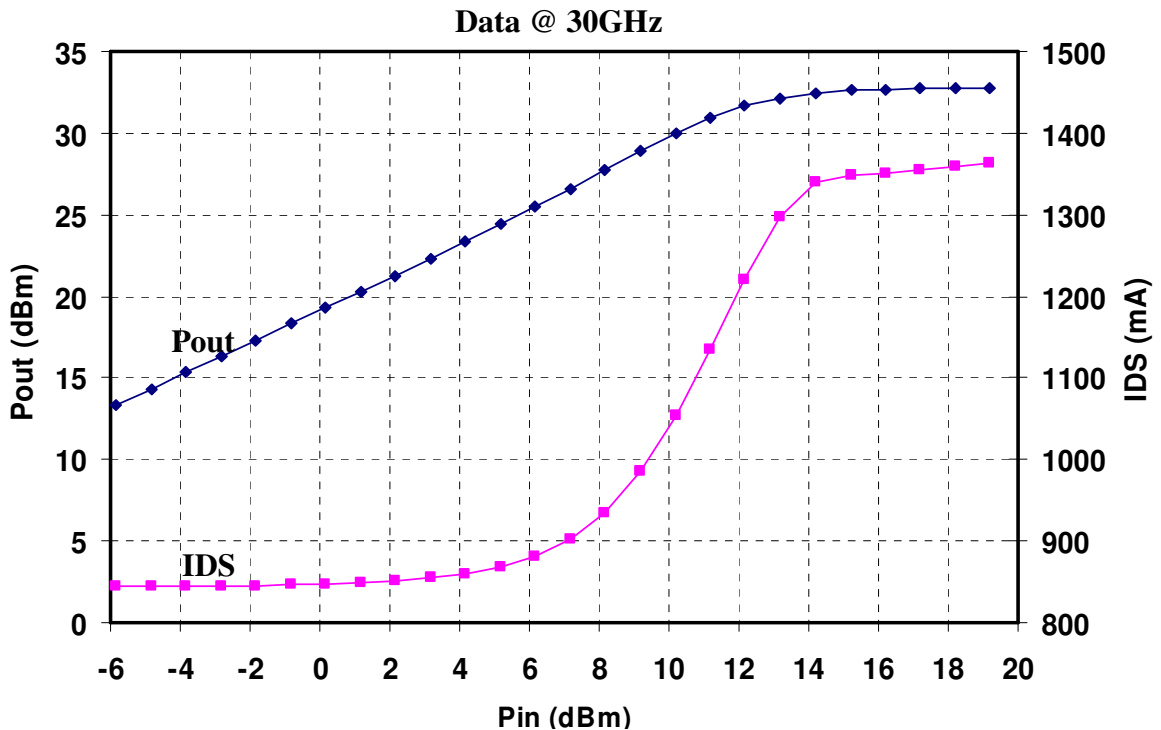
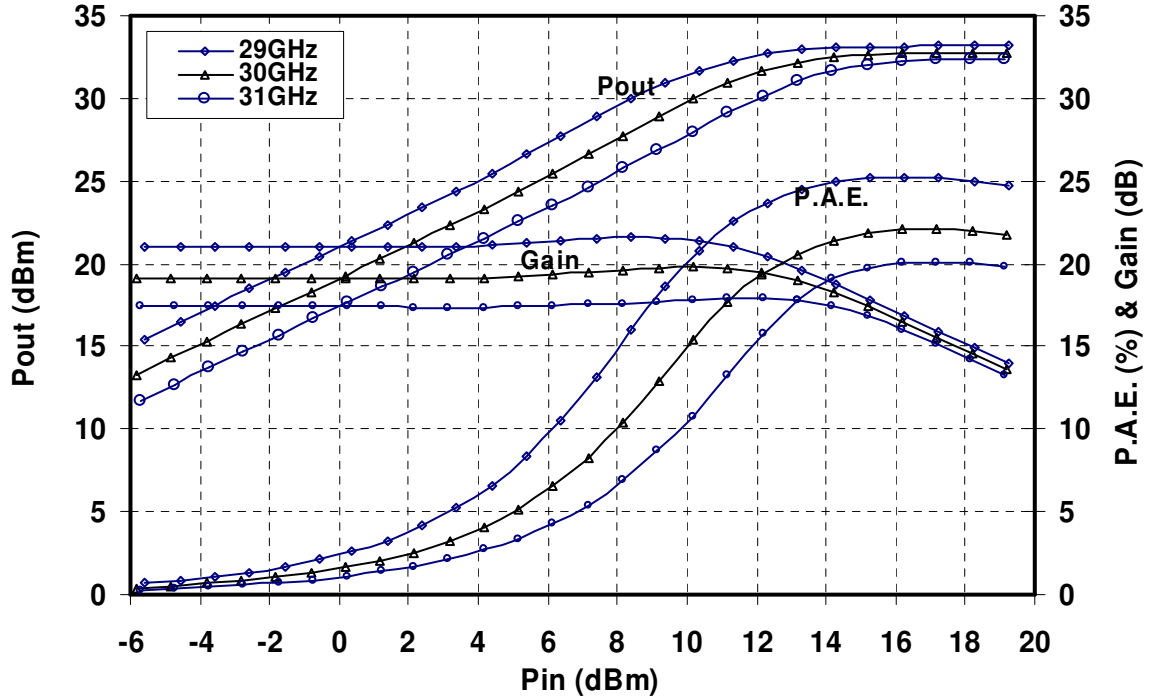
### Measured Data

Bias Conditions:  $V_d = 6\text{ V}$ ,  $I_d = 840\text{ mA}$



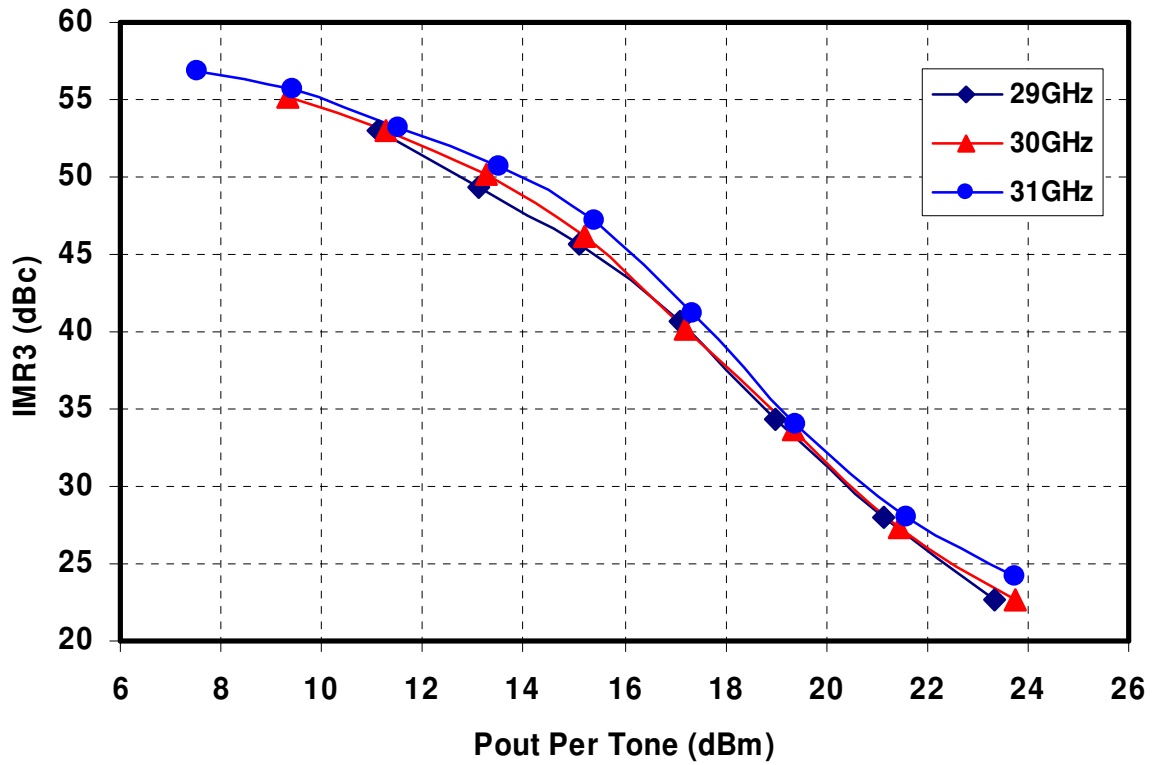
**Measured Data**

Bias Conditions: Vd = 6 V, Id = 840 mA

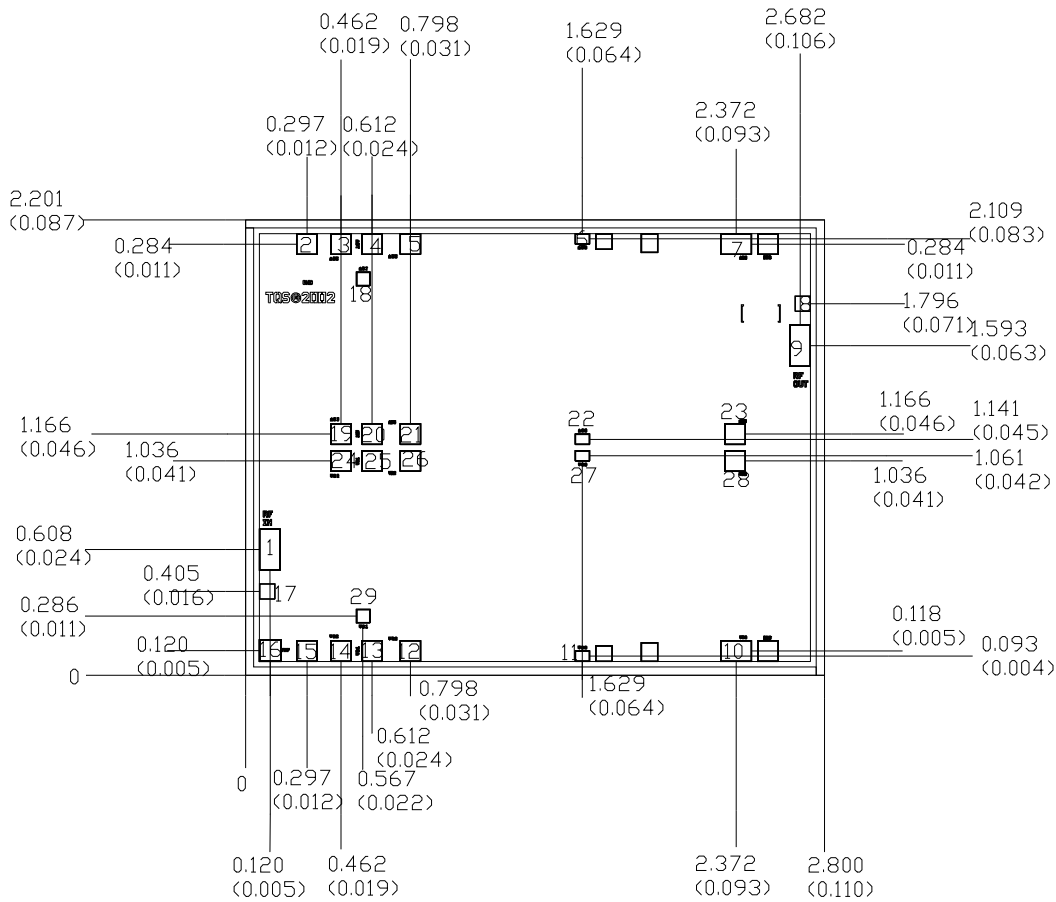


### Measured Data

Bias Conditions:  $V_d = 6\text{ V}$ ,  $I_d = 840\text{ mA}$ ,  $\Delta f = 10\text{ MHz}$



**Mechanical Drawing**



Units: millimeters (inches)

Thickness: 0.100 (0.004)

Chip edge to bond pad dimensions are shown to center of bond pad

Chip size tolerance: +/- 0.051 (0.002)

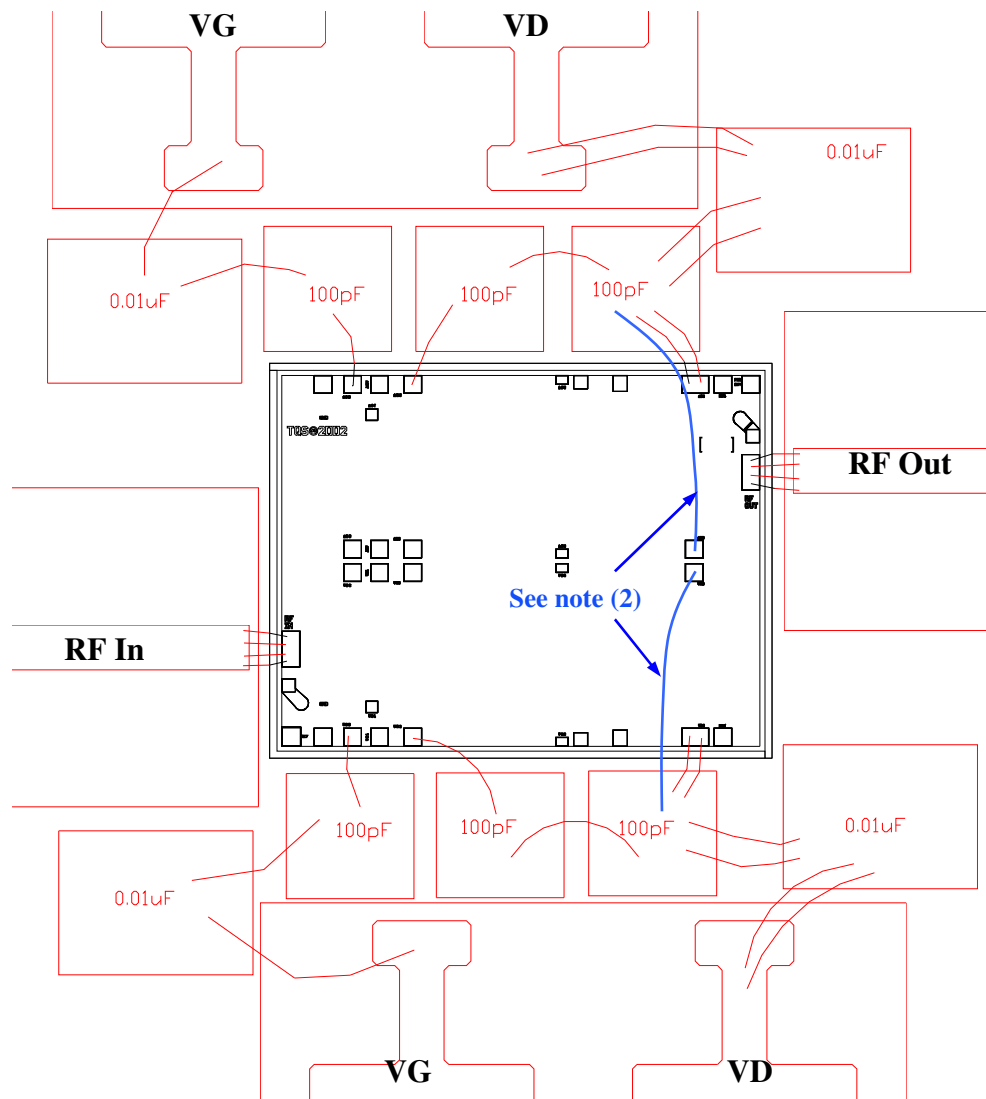
GND is back side of MMIC

Bond pad #1	RF In	0.100 x 0.200	(0.004 x 0.008)
Bond pad #2, 15, 16	N/C	0.100 x 0.100	(0.004 x 0.004)
Bond pad #3, 14, 19, 24	VG2	0.100 x 0.100	(0.004 x 0.004)
Bond pad #4, 13, 20, 25	VD1	0.100 x 0.100	(0.004 x 0.004)
Bond pad # 5, 12, 21, 26	VD2	0.100 x 0.100	(0.004 x 0.004)
Bond pad # 6, 11, 22, 27	VG3	0.070 x 0.050	(0.003 x 0.002)
Bond pad # 7, 10	VD3	0.150 x 0.100	(0.006 x 0.004)
Bond pad # 8, 17	N/C	0.075 x 0.075	(0.003 x 0.003)
Bond pad # 9	RF Out	0.100 x 0.200	(0.004 x 0.008)
Bond pad # 18, 29	VG1	0.065 x 0.065	(0.003 x 0.003)
Bond pad # 23, 28	VD3	0.100 x 0.100	(0.004 x 0.004)

**GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.**



**Chip Assembly Diagram<sup>(1)</sup>**



**Note**

- (1): Minimum 1 uF bypass Capacitors are required on both drain and gate power supplies.
- (2): Alternate configuration without these bondwires: the maximum positive supply current is reduced to 1.3A.

***GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.***

## **Assembly Process Notes**

Reflow process assembly notes:

- Use AuSn (80/20) solder with limited exposure to temperatures at or above 300°C (30 seconds max).
- An alloy station or conveyor furnace with reducing atmosphere should be used.
- No fluxes should be utilized.
- Coefficient of thermal expansion matching is critical for long-term reliability.
- Devices must be stored in a dry nitrogen atmosphere.

Component placement and adhesive attachment assembly notes:

- Vacuum pencils and/or vacuum collets are the preferred method of pick up.
- Air bridges must be avoided during placement.
- The force impact is critical during auto placement.
- Organic attachment can be used in low-power applications.
- Curing should be done in a convection oven; proper exhaust is a safety concern.
- Microwave or radiant curing should not be used because of differential heating.
- Coefficient of thermal expansion matching is critical.

Interconnect process assembly notes:

- Thermosonic ball bonding is the preferred interconnect technique.
- Force, time, and ultrasonics are critical parameters.
- Aluminum wire should not be used.
- Maximum stage temperature is 200°C.

***GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.***

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